

 $HR(0-10^{\circ},950-1170nm\pm10nm)>99.9\%$ ,  $GDD(0^{\circ},1000-1080nm)\sim -250\pm75fs^{2}$ 

fig. 1 reflection HR-region (unpolarized)

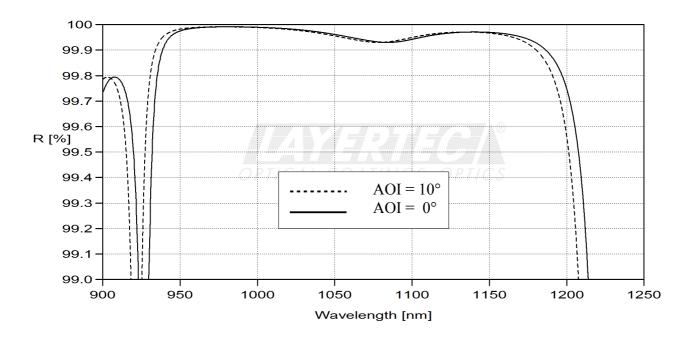


fig. 2 calculated GDD( $R,0^{\circ}$ ) with typically shift  $\pm 5$ nm of ZWL due to the production tolerance

